



[10191/2169]

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : BECKER et al. Confirmation No.: 8531

Serial No. : 10/031,842

Filed : June 10, 2002

For : DEVICE AND METHOD FOR ETCHING A SUBSTRATE
BY USING AN INDUCTIVELY COUPLED PLASMA

Examiner : S. Ahmed

Art Unit : 1765 I hereby certify that this correspondence is being deposited with
the United States Postal Service as first class mail in an envelope
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Atty's Signature

L. M. Maguire
DERVIS MAGISTRE
KENYON & KENYON

SIR:

In response to the restriction requirement dated
October 22, 2003, entry of the following election is respectfully
requested.

ELECTION

Applicants elect, with traverse, the claims of Group II,
namely, claims 49-67.

REMARKS

Applicants have elected, with traverse, claims 49-67.
Applicants traverse the restriction requirement because under Rule
475, Applicants are entitled to have all of claims 33-67 examined by
the Patent Office in this application. Rule 475(b)(4) reads, in
pertinent part, as follows:

An international or a national stage application containing
claims to different categories of invention will be
considered to have unity of invention if the claims are
drawn only to one of the following combinations of
categories:

(4) A process and an apparatus or means specifically
designed for carrying out the said process....

(Emphasis added). According to the cited portion of Rule 475, if the

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